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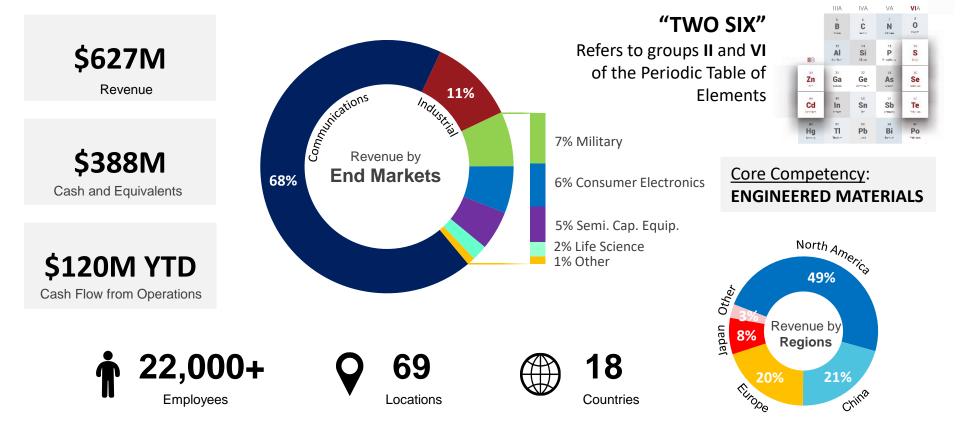
MATERIALS THAT MATTER

SiC-Based Materials and Devices Enabling Electrification and Mobility at Scale

May 29, 2020

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II-VI Incorporated Q3 FY2020 Overview



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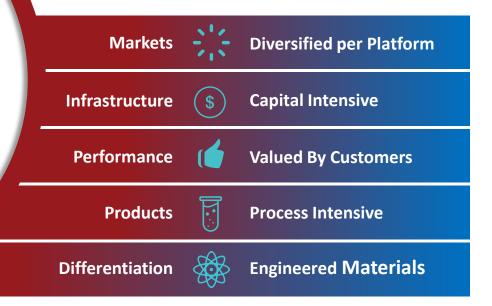
Core Strategy

Core Competency

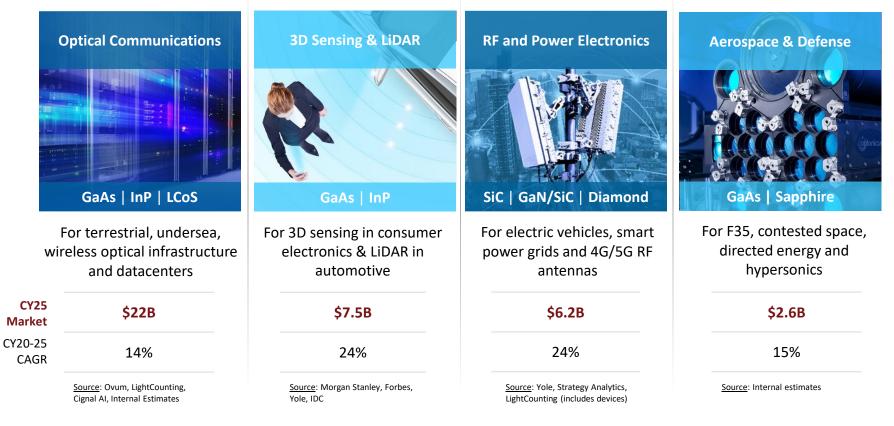
- A Leader in engineered materials and optoelectronic devices
- Differentiated lasers, optics, and integrated circuits
- Enabling the convergence of communications, computing, and sensing

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Innovation Strategy



Addressing Multiple Strong and Growing Markets



Updated on 4/9/2020

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Strategic Compound Semiconductor Platforms: SiC and GaN

Champaign, IL, USA

GaN and SiC EpiWafers

- GaN/SiC RF
- SiC/SiC Power
- Ongoing Expansion



Starkville, MS, USA

Back End SiC Wafer Processing

- Polish
- Clean
- Characterize
- Ship

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RF & Power Market



Easton, PA, USA

SiC Substrates (RF and Power)

- Crystal growth
- Ongoing Expansion
- > 250K sq.ft. space



Pine Brook, NJ, USA

SiC Substrates (RF and Power)

- R&D
- Crystal growth
- Slicing



Warren, NJ, USA

RF GaN/SiC Devices

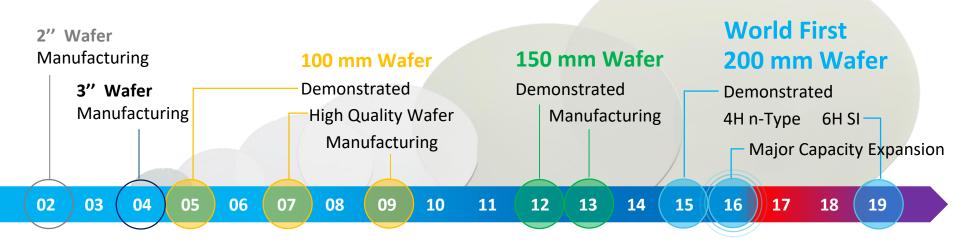
• GaN/SiC RF HEMT's



II-VI will be a key enabler of SiC and GaN compound semiconductor technology nodes

- Leading technology, vertical integration, scalable 150mm platform, supply chain security
- 5G wireless, green energy, EV/HEV

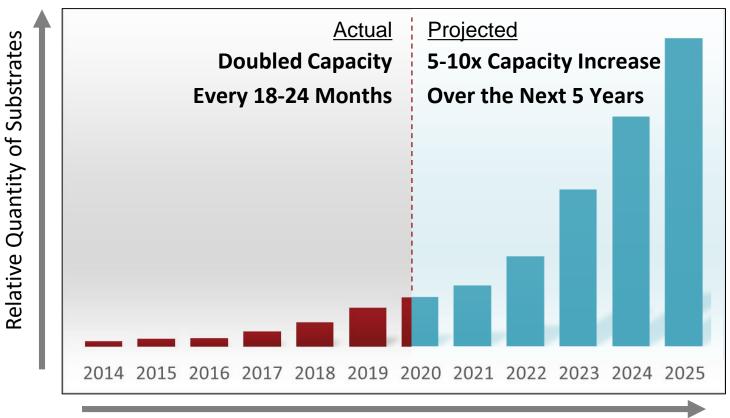
II-VI SiC Diameter Expansion Timeline



Advantages of Large Diameter Substrates

- Large diameter substrate fabrication cost (per unit area) is reduced significantly
- Large diameter wafer availability has helped move SiC-based devices from niche to mainstream
- Existing 200 mm silicon wafer fab lines can be used for SiC devices manufacturing

SiC Manufacturing Capacity Expansion



Calendar Year

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Enabling Electrification & Mobility

-

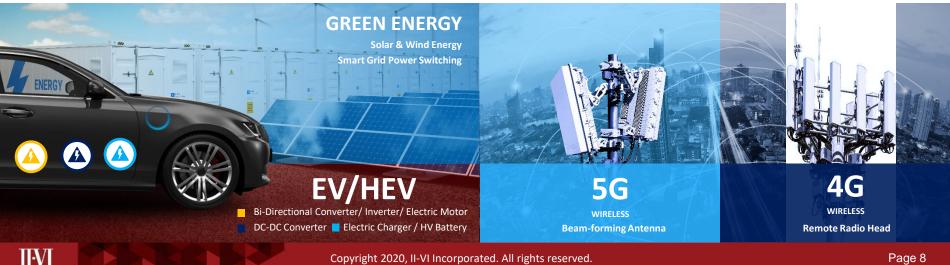
Ramping silicon carbide substrate capacity 5-10x over the next 5 years

POWER ELECTRONICS FOR ELECTRIC VEHICLES

- 100, 150 mm diameter **conductive** substrates
- 2015: World's first 200 mm conductive substrates
- For SiC MOSFETs power devices
- About 10% more driving distance on the same charge

RF ELECTRONICS FOR WIRELESS BASE STATIONS

- 100, 150 mm diameter **semi-insulating** substrates
- 2019: Word's first 200 mm semi-insulating substrates
- For SiC-based GaN HEMT devices
- GaN/SiC enables high-bandwidth 5G bands



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MATERIALS THAT MATTER